国外电子信息精品著作(影印版)

纳米电子学基础

Fundamentals of Nanoelectronics

George W. Hanson



科学出版社

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斜 学 出 版 社 北 京

内容简介

本书分三个部分,分别在纳米物理学、单电子效应和多电子效应方面进行介绍,内容丰富、论述详实。书中有很多实验结果用来支持文中描述的物理概念,这使读者能够看到概念的真实性以及在实际技术中的重要应用,还有大量的章末问题能加强读者解决问题的能力。本书是第一本真正适用于大学工程和应用科学学生的纳米电子学教科书。

Original edition, entitled FUNDAMENTALS OF NANOELECTRONICS, 1E, 9780131957084 by HANSON, GEORGE W., published by Pearson Education, Inc, publishing as Prentice, Copyright © 2008 Pearson Education, Inc.

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图书在版编目(CIP)数据

纳米电子学基础 = Fundamentals of Nanoelectronics: 英文/(美)汉森(Hanson G. W.)编著. 一影印版. —北京:科学出版社, 2012

(国外电子信息精品著作)

ISBN:978-7-03-034382-6

I.纳··· II.汉··· III.纳米材料-电子器件-英文 IV. TN103 中国版本图书馆 CIP 数据核字(2012)第 103155 号

责任编辑:张宇 余丁 / 责任印制:张倩 / 封面设计:陈敬

分 学 虫 版 社 出版 北京东黄城根北街 16号 邮政编码: 100717

http://www.sciencep.com

新科印刷有限公司 印刷

科学出版社发行 各地新华书店经销

2012年6月第 一 版 开本: 787×1092 1/16 2012年6月第一次印刷 印张: 25 1/4 字数: 578 000

定价: 80.00元

(如有印装质量问题,我社负责调换)

《国外电子信息精品著作》序

20世纪 90 年代以来,信息科学技术成为世界经济的中坚力量。随着经济全球化的进一步发展,以微电子、计算机、通信和网络技术为代表的信息技术,成为人类社会进步过程中发展最快、渗透性最强、应用面最广的关键技术。信息技术的发展带动了微电子、计算机、通信、网络、超导等产业的发展,促进了生命科学、新材料、能源、航空航天等高新技术产业的成长。信息产业的发展水平不仅是社会物质生产、文化进步的基本要素和必备条件,也是衡量一个国家的综合国力、国际竞争力和发展水平的重要标志。在中国,信息产业在国民经济发展中占有举足轻重的地位,成为国民经济重要支柱产业。然而,中国的信息科学支持技术发展的力度不够,信息技术还处于比较落后的水平,因此,快速发展信息科学技术成为我国迫在眉睫的大事。

要使我国的信息技术更好地发展起来,需要科学工作者和工程技术人员付出艰辛的努力。此外,我们要从客观上为科学工作者和工程技术人员创造更有利于发展的环境,加强对信息技术的支持与投资力度,其中也包括与信息技术相关的图书出版工作。

从出版的角度考虑,除了较好较快地出版具有自主知识产权的成果外,引进国外的优秀出版物是大有裨益的。洋为中用,将国外的优秀著作引进到国内,促进最新的科技成就迅速转化为我们自己的智力成果,无疑是值得高度重视的。科学出版社引进一批国外知名出版社的优秀著作,使我国从事信息技术的广大科学工作者和工程技术人员能以较低的价格购买,对于推动我国信息技术领域的科研与教学是十分有益的事。

此次科学出版社在广泛征求专家意见的基础上,经过反复论证、 仔细遴选,共引进了接近30本外版书,大体上可以分为两类,第一 类是基础理论著作,第二类是工程应用方面的著作。所有的著作都涉 及信息领域的最新成果,大多数是2005年后出版的,力求"层次高、 内容新、参考性强"。在内容和形式上都体现了科学出版社一贯奉行的严谨作风。

当然,这批书只能涵盖信息科学技术的一部分,所以这项工作还 应该继续下去。对于一些读者面较广、观点新颖、国内缺乏的好书还 应该翻译成中文出版,这有利于知识更好更快地传播。同时,我也希 望广大读者提出好的建议,以改进和完善从书的出版工作。

总之,我对科学出版社引进外版书这一举措表示热烈的支持,并 盼望这一工作取得更大的成绩。

玉越

中国科学院院士 中国工程院院士 2006年12月



PREFACE

Nanotechnology refers to any technology that uses nanoscopic objects or devices, i.e., devices on the order of a nanometer (one nanometer is one billionth of a meter). This is roughly the size one would obtain by shrinking a grain of sand by a factor of one thousand, and then again by another factor of one thousand. Thus, it is the technology of the very small.

While there has been considerable hype in the popular media about the promises, and possible perils, of nanotechnology, the field is truly in its infancy. At this time it is impossible to know which aspects of nanotechnology currently under consideration will lead to mature, established fields and to practical applications. It is certain, however, that many as-yet unimagined areas of nanotechnology will be developed in the future. It is also certain that nanotechnology will play an increasingly important role in everyday life, as devices move from the research laboratory to the commercial market.

To develop nanotechnology, scientists and engineers need to understand the fundamental physical principles governing objects having dimensions on the order of nanometers. This is the realm of quantum mechanics, in general, as well as related areas in solid state physics, chemistry, and biology. For example, although there are many proposals to develop

nanoscale devices based on electron movement in metals and semiconductors, there is also considerable interest in developing chemical and biological computers, molecular electronics, and other information processing devices outside of the traditional electron physics disciplines.

This book was written to provide an introduction to fundamental concepts of nanoelectronics, including single electron effects and electron transport in nanoscopic systems, for electrical engineers and applied scientists. The intended audience for the book is junior and senior level undergraduate students, although it can also serve as an introduction to the subject for beginning graduate students. Of paramount importance is the idea of understanding quantum dots, quantum wires, and quantum wells, and nanoelectronic applications of these structures. In particular, attention is focused on the quantization of electrical properties, such as conductance quantization and ballistic transport in low-dimensional systems, quantum interference effects arising from the wave nature of electrons, and tunneling phenomena in nanoelectronic devices. Topics were chosen that emphasize, to a large degree, quantum counterparts of classical electronic and electrical devices familiar to junior and senior level undergraduate students, such as transistors and wires. The level of presentation assumes that the reader has some background in basic physics, including fundamental concepts in mechanics, energy, and electromagnetics, and in electrical circuits and traditional electronics. Furthermore, some basic knowledge of the physics of field-effect transistors would be helpful. In the electrical engineering curriculum at most universities, such background material has usually been covered by some point in the junior year.

Although quantum mechanics and solid state physics are treated at an introductory level, the book is not intended to replace discipline specific books or courses in these areas. However, in the ever-increasingly congested undergraduate curriculum at most institutions, a course such as the one this book is intended to accompany can serve as an introduction to the area, and spur interest for further study.

ACKNOWLEDGMENTS

I would like to thank Patricia Whaley and the folks at Quantum Dot Corporation for their helpful comments, and Peter Burke for sharing his expertise, and for his thoughtful considerations of this work. I would also like to thank Richard Sorbello and Carolyn Aita at the University of Wisconsin-Milwaukee for their help, and for their encouragement and interest in this area. Furthermore, Iam grateful to the anonymous reviewers who provided detailed comments and suggestions that significantly improved this work.

PHOTO CREDITS

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